

Design of TiO₂-SiC photocatalyst using TiC-SiC nano-particles for degradation of 2-propanol diluted in water

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Abstract

TiO₂ photocatalyst deposited on SiC (TiO₂-SiC) was prepared by a calcination of nano-particles of TiC-SiC precursor obtained by a carbothermic reduction of SiO₂-TiO₂. The formation of the mixture of well-crystallized anatase and rutile phases of TiO₂ was observed on the calcined TiO₂-SiC photocatalyst, while amorphous TiO₂ species was main component on the TiO₂-SiO₂ photocatalyst prepared by a conventional sol-gel method. From the measurement on the water adsorption ability of photocatalysts, the TiO₂-SiC photocatalyst exhibited the hydrophobic surface property in comparison with TiO₂-SiO₂ and commercial TiO₂ powder (P-25) photocatalysts. Under UV-light irradiation, the TiO₂-SiC photocatalyst decomposed 2-propanol diluted in water into acetone, CO₂, and H₂O, and finally acetone was also decomposed into CO₂ and H₂O. The TiO₂-SiC photocatalyst exhibited the higher photocatalytic reactivity than TiO₂-SiO₂ photocatalyst prepared by the sol-gel method. Well-crystallized TiO₂ phase deposited on SiC and the hydrophobic surface of SiC support are important factors for the enhancement of photocatalytic reactivity for degradation of organic compounds in the liquid phase reaction.

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1. Introduction

The design of highly efficient photocatalytic systems which work for the reduction of global atmospheric pollution and the purification of polluted water is of vital interest. TiO₂ semiconductor is known as one of the most stable and highly reactive photocatalysts [1–7]. The utilization of extremely small TiO₂ particles as photocatalysts has attracted a great deal of attention, especially for environmental applications. Because TiO₂ photocatalyst can completely mineralize toxic and nonbiodegradable organics to CO₂, H₂O, and inorganic constituents, many researches have been undertaken to purify polluted water by using TiO₂ photocatalyst.

For practical utilization of photocatalyst TiO₂ having higher photocatalytic reactivity is desirable. During the process of purification of polluted water, photocatalyst has to be separated

from treated water. To separate the photocatalyst from water, photocatalyst has to be supported on bulk materials. It has been found that the highly dispersed titanium oxide photocatalysts anchored on the porous silica-based materials exhibit high and characteristic photocatalytic reactivity compared to bulk TiO₂ powder [1,6,7]. Especially the titanium oxide species prepared within the pores and frameworks of zeolite and mesoporous silica have been revealed to have unique local structures as well as high reactivity in the various photocatalytic reactions [8,9]. Furthermore, TiO₂ photocatalyst loaded on Si₃N₄ has also been successfully utilized as the catalyst for the photocatalytic degradation of pollutants diluted in water [10].

On the other hand, silicon carbide (SiC) has various attractive properties such as high thermostability, high mechanical strength, and high electrical conductivity. In addition, SiC is easy to be molded into a filter and has been used as catalyst support [11–17]. Although it may be a useful support for photocatalysts used in liquid phase, there have been no reports on the properties of TiO₂ photocatalysts loaded on SiC. Only the study on the photocatalysis of TiO₂ deposited on

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the fiber of precursor SiC material has been reported in the similar system [18].

Recently, it has been found that nano-size TiC-SiC particles can be synthesized by a carbothermic reduction of SiO₂-TiO₂ [13]. In the present study, we deal with the preparation and characterization of TiO₂ photocatalysts loaded on SiC using the TiC-SiC precursor obtained by the carbothermic reduction of SiO₂-TiO₂ and carried out its successful utilization for the photocatalytic degradation of 2-propanol diluted in water.

2. Experimental

2.1. Preparation of catalysts

By the process for preparation of nano-size TiC-SiC particles reported in the previous study [13], the liquid mixtures of titanium tetraisopropoxide (TPOT), tetraethyl orthosilicate (TEOS), and phenolic resin were prepared. After the continuous stirring of the mixtures to the gelation, the obtained gels were dried in vacuum, and pyrolyzed at 1273 K in a nitrogen atmosphere. The material pyrolyzed at 1273 K was preheated at 1873 K under Ar flow to yield the TiC-SiC precursor by the carbothermic reduction. The obtained TiC-SiC powders were then calcined in air at 773 K and 1073 K to synthesize TiO₂ deposited on SiC powder (TiO₂-SiC). In order to compare photocatalytic reactivity with TiO₂-SiC, TiO₂-SiO₂ samples were prepared by the conventional sol-gel method using TEOS, TPOT, and ethanol [6].

2.2. Characterization of catalysts

X-ray diffraction (XRD) patterns of the samples were measured by Rigaku RINT2500 diffractometer with Cu K α 1 radiation. X-ray photoelectron spectroscopy (XPS) was recorded with JEOL microprobe system using the Mg K α line. The XAFS spectra (XANES and EXAFS) were measured at the BL-9A facility [19] of the Photon Factory at the National Laboratory for High-Energy Physics, Tsukuba. A Si(1 1 1) double crystal was used to monochromatize the X-rays from the 2.5 GeV electron storage ring. The normalized spectra were obtained by a procedure described in previous literature [20]. Water adsorption isotherms of the catalysts were recorded at 293 K using vacuum line system.

2.3. Photocatalytic degradation

The photocatalyst (50 mg) was transferred to a quartz cell with an aqueous solution of 2-propanol (2.6×10^{-3} mol dm⁻³, 25 ml). Prior to UV-light irradiation, the suspension was stirred in a flow of O₂ for 1 h under dark conditions. The sample was then irradiated ($1300 \mu\text{W cm}^{-2}$ at 340–370 nm) at 295 K using UV light ($\lambda > 250$ nm) from a 100 W high-pressure Hg lamp with continuous stirring under O₂ atmosphere in the system [7]. The products were analyzed by gas chromatography. The photocatalytic reactivity was estimated from the initial decrease in the concentration of 2-propanol after preadsorption of 2-propanol on the catalyst under dark condition.

3. Results and discussion

Fig. 1 shows the XRD patterns of untreated TiC-SiC precursor and TiO₂-SiC photocatalysts oxidized at 773 K and 1073 K, respectively. In the TiC-SiC precursor, very sharp peak corresponding to TiC and SiC were observed indicating that well-crystallized TiC-SiC material was obtained. After calcination, the formation of the mixture of anatase and rutile phases of TiO₂ crystalline was observed on TiO₂-SiC samples. At higher calcination temperature crystal size of TiO₂ grew up. The size of crystalline of sample calcined at 1073 K can be estimated from XRD line width as 18 nm (anatase), 17 nm (rutile), and 22 nm (SiC), respectively. On the other hand, TiO₂-SiO₂ photocatalysts prepared by the sol-gel method and calcined at 773 K exhibited no XRD peak due to the crystallized phases, indicating that the TiO₂ species exist in an amorphous phase.

Fig. 2 shows XANES spectra at Ti K-edge of untreated TiC-SiC precursor and TiO₂-SiC photocatalysts oxidized at 773 K and 1073 K, respectively. The XANES spectra at the Ti K-edge showed several well-defined preedge peaks which are related to the local structure surrounding the Ti atom. The relative intensities of these preedge peaks provide useful information on the coordination number of the Ti atom [21]. TiO₂-SiC prepared by the oxidation at 1073 K exhibit three small well-defined preedge peaks which can be assigned to the presence of anatase phase with high crystallinity as a main species. These results obtained from XRD and XAFS measurements indicate that the TiC species of TiC-SiC precursor can be oxidized easily to form the mixture of anatase and rutile TiO₂ crystalline at 773 K and crystallized mainly into anatase TiO₂ at 1073 K on the SiC support.

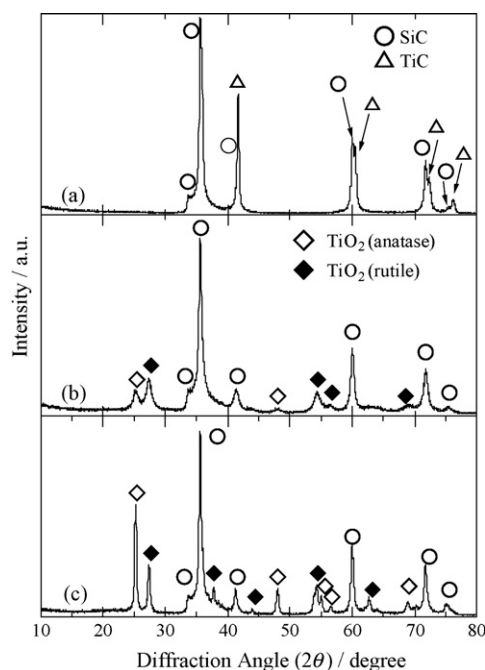


Fig. 1. XRD patterns of untreated TiC-SiC (a) and TiO₂-SiC photocatalysts prepared by calcination at 773 K (b) and 1073 K (c), respectively.

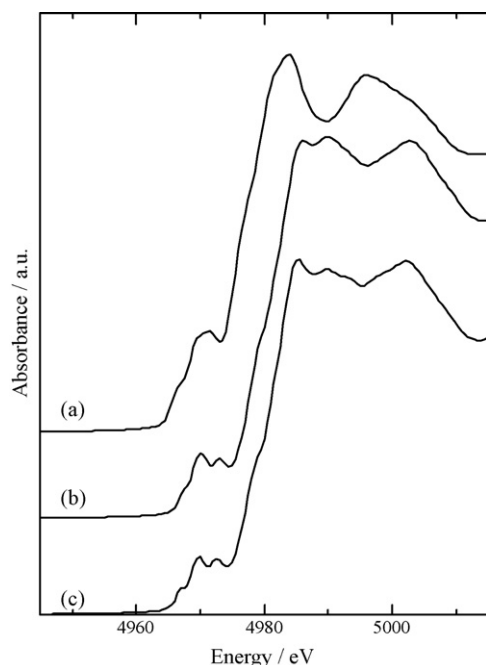


Fig. 2. Ti K-edge XANES spectra of untreated TiC-SiC (a) and TiO₂-SiC photocatalysts prepared by calcination at 773 K (b) and 1073 K (c), respectively.

Figs. 3 and 4 shows the Ti 2p and Si 2p XPS spectra measured with TiC-SiC precursor and TiO₂-SiC photocatalysts calcined at 773 K and 1073 K, respectively. The changes in the XPS bands after the calcination indicated that TiO₂ exists on the surface by calcination of TiC-SiC precursor at 773 K, while SiC is not oxidized. At higher calcination temperature (1073 K) not only TiC is oxidized into TiO₂ but also SiC is partially oxidized

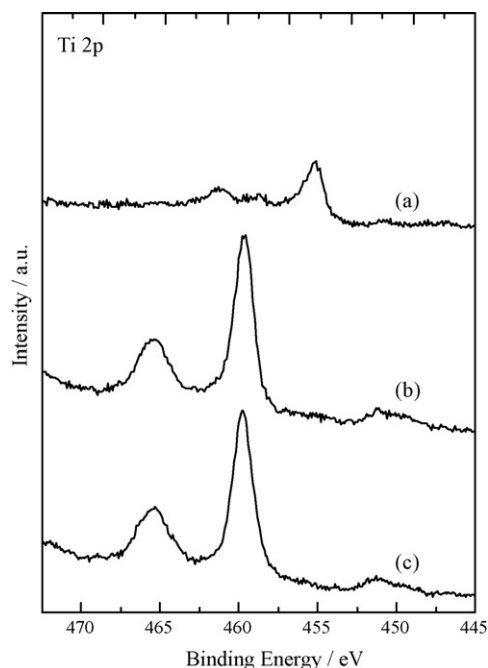


Fig. 3. Ti 2p XPS spectra of untreated TiC-SiC (a) and TiO₂-SiC photocatalysts prepared by calcination at 773 K (b) and 1073 K (c), respectively.

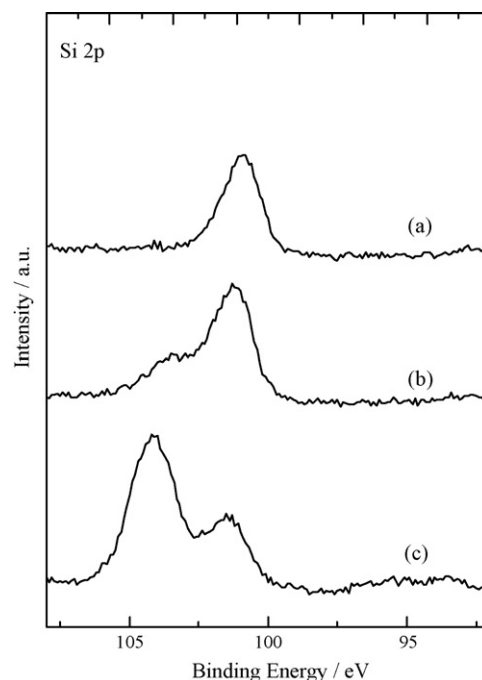


Fig. 4. Si 2p XPS spectra of untreated TiC-SiC (a) and TiO₂-SiC photocatalysts prepared by calcination at 773 K (b) and 1073 K (c), respectively.

into SiO₂ and form the mixture of SiC and SiO₂ on the surface of catalyst.

Scheme 1 shows the systematic diagrams for the formation of TiO₂-SiC photocatalyst prepared by the calcination of nano-size TiC-SiC precursor particles. During the calcination, TiC is oxidized more easily than SiC and deposited on the surface of SiC, while the surface SiC was oxidized partially at the higher calcination temperatures.

Fig. 5 shows the reaction time profiles of the liquid phase photocatalytic degradation of 2-propanol diluted in water on the TiO₂-SiC photocatalysts calcined at 773 K and 1073 K, TiO₂-SiO₂ photocatalyst prepared by the sol-gel method, and commercial TiO₂ powder (P-25). Under UV-light irradiation of photocatalysts 2-propanol is decomposed into acetone, CO₂,

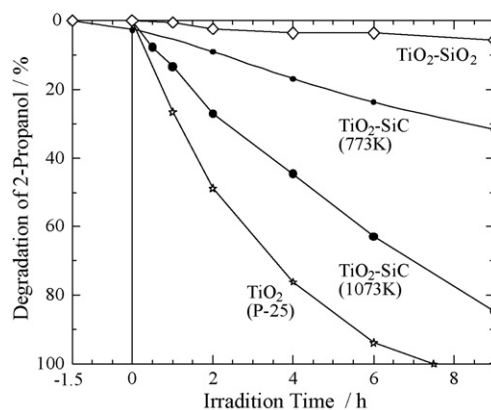
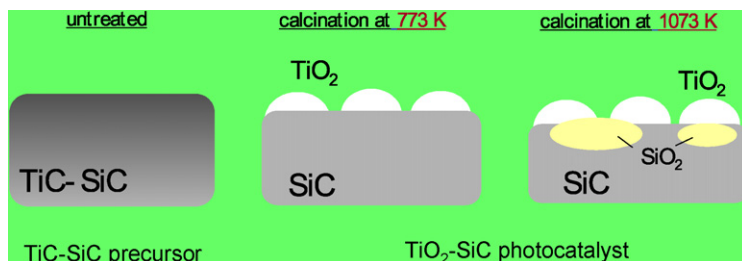


Fig. 5. Time profile for photocatalytic degradation of 2-propanol diluted in water on TiO₂-SiC photocatalyst calcined at 773 K and 1073 K, TiO₂-SiO₂ photocatalyst prepared by the sol-gel method followed by calcination at 1073 K, and commercial TiO₂ powder (P-25).



Scheme 1. Scheme for the formation of TiO_2 -SiC photocatalyst from the precursor of nano-particles of TiC-SiC.

and H_2O , and finally, acetone is also decomposed into CO_2 and H_2O , as similar to the reaction scheme observed on TiO_2 /HMS mesoporous silica [22]. The TiO_2 -SiC photocatalysts decomposed 2-propanol faster than TiO_2 - SiO_2 photocatalyst prepared by the sol-gel method. This result indicates that SiC is useful support for TiO_2 photocatalyst for degradation of organic compounds in water. Among the TiO_2 -SiC catalysts, the photocatalyst calcined at 1073 K shows the higher reactivity than the photocatalyst calcined at 773 K.

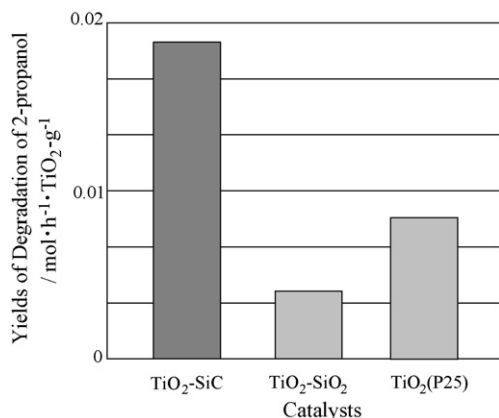


Fig. 6. Photocatalytic reactivity normalized per weight of TiO_2 for 2-propanol diluted in water on TiO_2 -SiC photocatalysts calcined at 773 K and 1073 K, TiO_2 - SiO_2 photocatalyst prepared by the sol-gel method followed by calcination at 1073 K, and commercial TiO_2 powder (P-25).

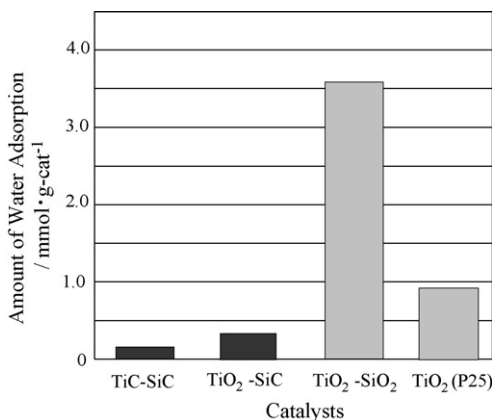


Fig. 7. Amount of water adsorption on untreated TiC-SiC, TiO_2 -SiC photocatalysts calcined at 1073 K, TiO_2 - SiO_2 photocatalyst prepared by the sol-gel method followed by calcination at 1073 K, and commercial TiO_2 powder (P-25).

Fig. 6 shows the photocatalytic reaction rate normalized per weight of TiO_2 of various catalysts estimated from the initial decrease in the concentration of 2-propanol. TiO_2 -SiC photocatalyst prepared by the calcination of TiC-SiC at 1073 K exhibited the higher photocatalytic reactivity than TiO_2 - SiO_2 photocatalyst prepared by the conventional sol-gel method and commercial TiO_2 powder P-25. This result indicates that well-crystallized TiO_2 deposited on SiC can demonstrate efficient photocatalytic reactivity.

Fig. 7 shows the amount of water adsorption on various catalysts. Amount of water adsorption on TiO_2 -SiC photocatalyst prepared at 1073 K is much smaller than TiO_2 - SiO_2 and TiO_2 powder (P-25). This result suggests that SiC support has the hydrophobic surface property. As reported previously [22], the photocatalytic reactivity of TiO_2 loaded on supports depend significantly on the hydrophilic-hydrophobic surface property of supports and the hydrophobic surface property is suitable for the photocatalytic degradation of organics diluted in water. In the present reaction system, the hydrophobic surface property of SiC support is also very important factor for the efficient photocatalytic reactivity of TiO_2 -SiC photocatalyst for the liquid phase reaction.

4. Conclusions

TiO_2 photocatalysts deposited on SiC (TiO_2 -SiC) which was prepared by the calcination of the TiC-SiC precursor showed high photocatalytic reactivity for the degradation of 2-propanol diluted in water. Comparing the reactivity per weight of TiO_2 , TiO_2 -SiC photocatalyst showed the higher photocatalytic reactivity than TiO_2 - SiO_2 photocatalyst prepared by the conventional sol-gel method and commercial TiO_2 powder. The formation of well-crystallized TiO_2 on SiC and the hydrophobic surface of SiC were found to be related to the efficient photocatalytic reactivity of TiO_2 -SiC photocatalyst. Since SiC is mechanically strong enough to be used as a filter for water purification, SiC is a good support for TiO_2 photocatalysts used in liquid phase reactions.

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